

Advanced NEMFET-based Power Management for deep-submicron Integrated Circuits

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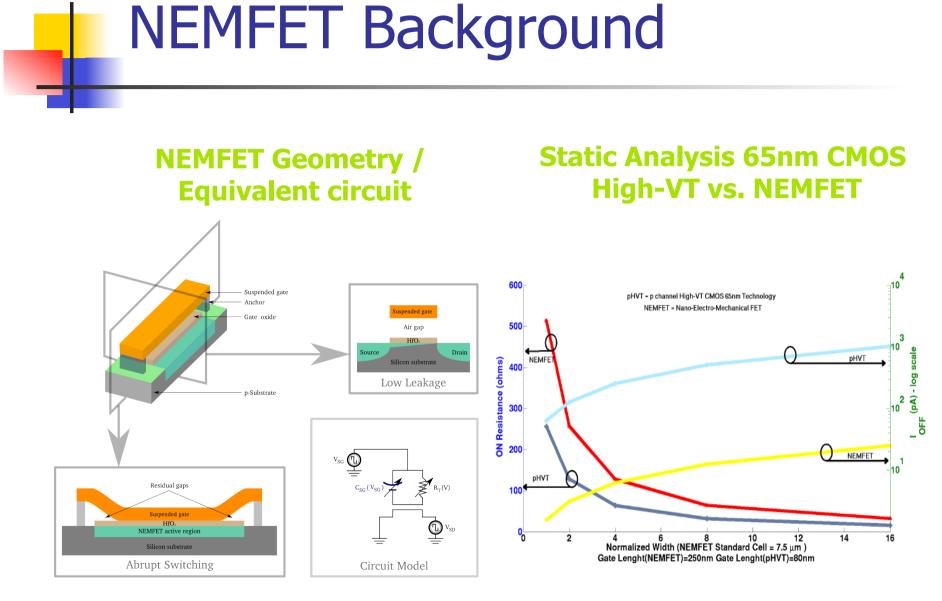


- CMOS technology is approaching its physical limits.
 - Emerging technologies have been investigated and proposed to supersede the MOSFET, e.g., Nano-Electro - Mechanical FETs (NEMFETs), carbon nanotubes, quantum dot cellular automata, single-electron devices.
 - Only low complexity circuits were successfully designed with the above technologies.
- 3D-Stacked IC (3D-SIC) may provide a smooth transition between CMOS and emerging devices.
 - It is a technology that potentially provides heterogeneous integration, higher performance, and lower power consumption, when compared to planar ICs.
- Scaling CMOS technology could still provide 30% improvement in performance at the 28 nm node with respect to the 40 nm node.
 - Tremendous increase of power dissipation of digital CMOS.
 - The life of the battery operated embedded systems with low activity, which is mostly determined by the standby leakage power dissipated by the circuit in sleep mode, is directly affected.

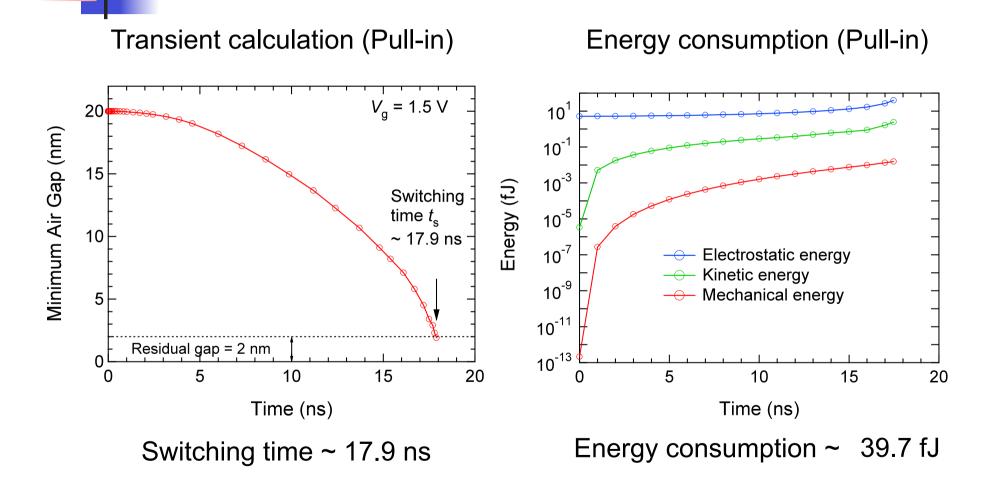


A Hybrid CMOS-NEMS 3D Stacked Chip Power Management Architecture.

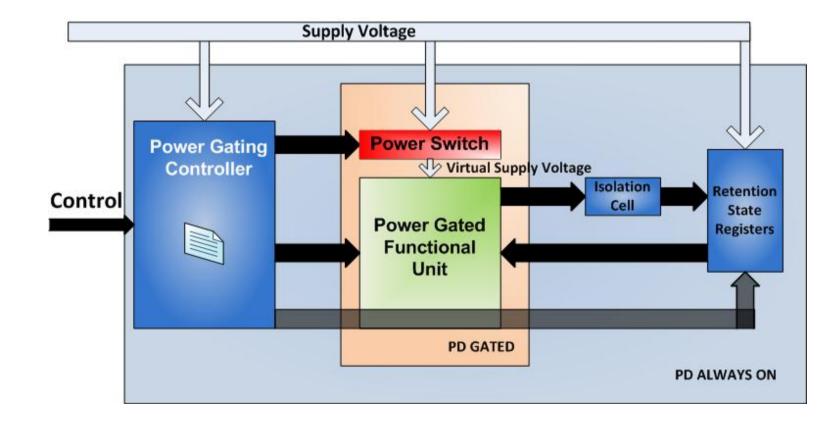




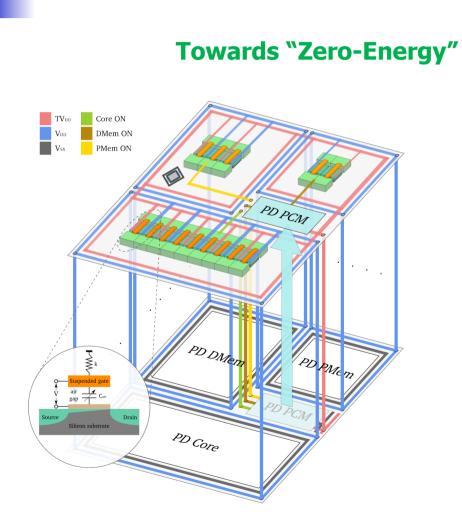
NEMFET Dynamic Behavior



Power Management



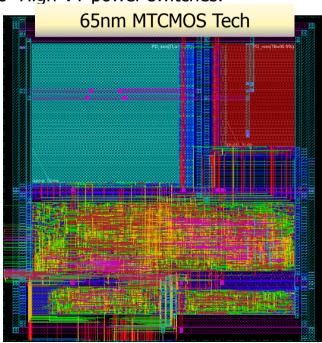
3D Power Management



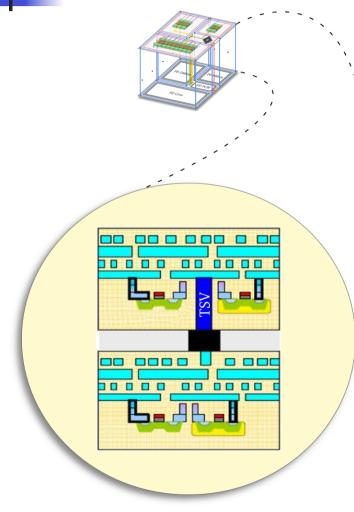
- Area reclaimed on the CMOS Tier
 - Signal interconnect length inside/ between gated components,
 - "True" VDD (TVDD) supply rings surrounding gated blocks are translated to the NEMS tier.
- Easy to integrate hybrid
 - devices technologies
 - Low-leakage NEMFET device,
 - Energy scavengers,
 - Temperature sensors, etc.
- IP Reuse
- Power management controller and always-on cells placed on:
 - CMOS tier or NEMS tier.

A Case Study

- Heart beat rate monitor Detects QRS complex in an Digitized Electrocardiogram (ECG).
 - Step 1. Identifies the R peaks in the ECG signal.
 - Step 2. Measures the interval between two consecutive R peaks.
- Four Designs
 - Reference Design 1 TIER design with "classic" High-VT power switches.
 - 16-bit openMSP 430
 - DMEM 2kB SRAM
 - PMEM 4kB ROM
 - Peripherals
 - Stacked Design 2 TIER design
 - Bottom TIER openMSP430 based SoC
 - Hybrid Design 2 TIER design
 - Bottom TIER openMSP430 based SoC
 - Top TIER PSO devices: NEMFETs
 - Leakage Enhanced Design 2 TIER design
 - Top TIER PSO devices: NEMFETs
 - Top TIER PSO and PM Cells: NEMFETs



A Case Study (2)



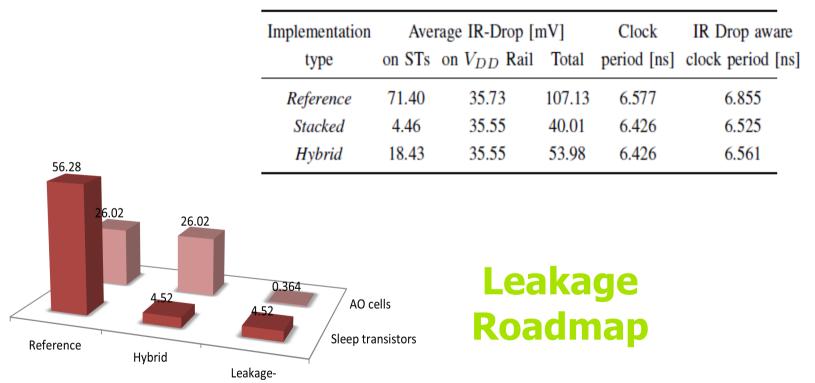
- Large metal vias connecting adjacent dies
- 5 μ m diameter
- 20 μ m length
- 10 μ m pitch
- R ≈ 0.2 Ω / entire TSV → low IR-drop in ON state
- C ≈ 40 fF →
 limits the granularity of the power gating

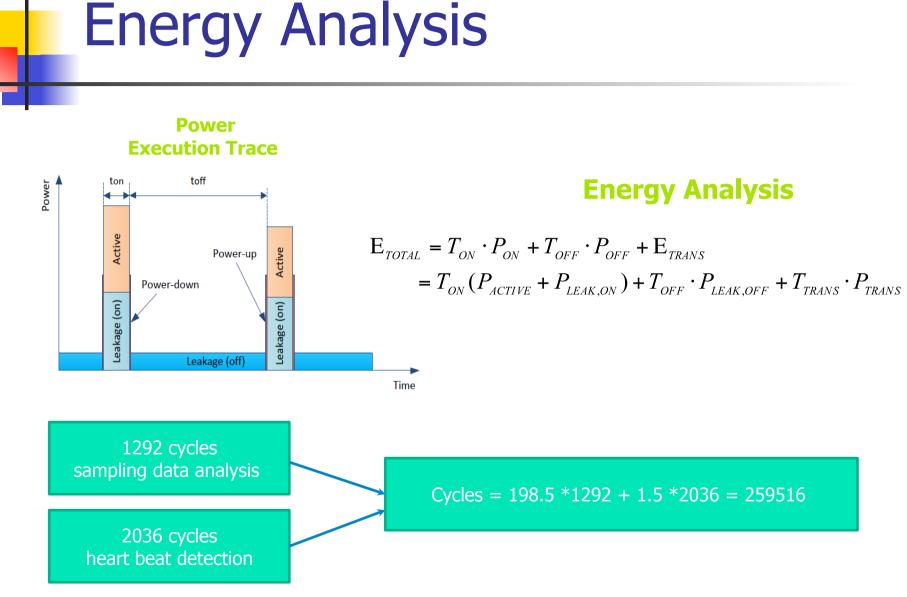
TSV model based on Katti et. al. (IEDM, 2010)

Delay and Leakage Analysis

- Delay degradation
 - "interruption" of the power/ground (P/G) rails by the power switch
 - IR Drop on the power supply net

enhanced





Energy Analysis (2)

Implementati on type	ON power [mW]	OFF power [nW]			Power-up	Total	Energy- Delay
		STs	Always- on cells	Total	energy [pJ]	energy [µJ]	Product [µJ·ns]
Reference	5.0340	56.28	26.02	81.28	48.04	9.05	62.01
Hybrid	5.0339	4.52	26.02	29.52	37	8.61	56.47
Leakage- Enhanced	4.7	4.52	0.364	4.884	37	8	51.48

Active time = 1.73 ms, Idle time = 993.35 ms, Transition time = 5.32 ms @ 150 MHz

Improvements

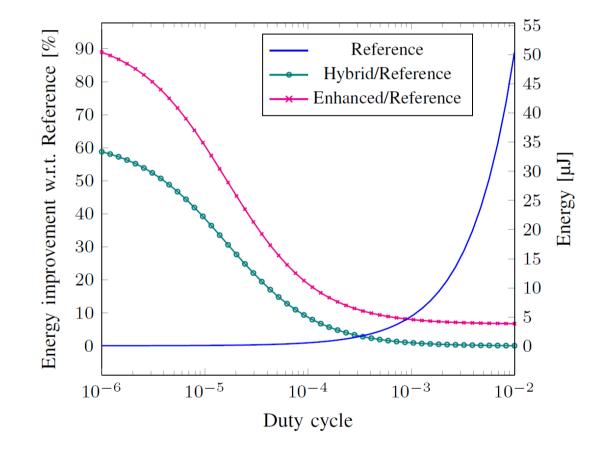
16.64X

17%

- State-of-the-art piezoelectric vibration scavengers from Aktakka et. al.:
 - power density of 6.45 μ W/mm³/g²
- Our assumptions:1g constant acceleration

=> for 8µJ, 1,24mm³

Duty Cycle vs. Energy Improvement





- The proposed architecture can help ubiquitous embedded nanosystems cope with very tight energy budgets.
- Promising candidate in reaching truly "zero-energy" ubiquitous nano-systems.
- Specifically effective for low activity applications.
- Energy evaluation of the Enhanced design indicated a reduction of 7% over the 3D Hybrid architecture and of about 15% with respect to the 2D CMOS counterpart.
- For applications with lower activity, the potential energy improvement can reach up to 90%, with respect to the 2D CMOS Reference design.